

(24) **POSITIONING SYSTEM AND POSITION MEASURING METHOD FOR USE IN EXPOSURE APPARATUS**

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(*) Notice: Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 0 days.

(21) Appl. No.: 09/314,170

(22) Filed: May 19, 1999

(30) **Foreign Application Priority Data**

May 21, 1998 (JP) 10-139740
Mar. 26, 1999 (JP) 11-063495

(51) Int. Cl.⁷ G03B 27/42; G03B 27/58

(52) U.S. Cl. 355/72; 355/53

(58) Field of Search 355/53, 72, 75;
356/399, 400, 401; 318/625, 632, 628,
687; 250/548

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(57) **ABSTRACT**

A positioning system includes a movable member being movable along a reference plane containing first and second directions, and a position measuring device for measuring positional information related to the movable member, wherein the movable member includes an element having a reflection surface inclined with respect to the reference plane, and wherein the position measuring device includes a measuring system for causing a measurement beam to be reflected by the inclined reflection surface and for detecting positional information related to the movable member with respect to a direction intersecting the reference plane.

63 Claims, 29 Drawing Sheets

